



Continuation of Substance of Interview including description of the general nature of what was discussed: The examiner contacted Mr. Parzych to inform him that claims 20 and 21 were amended to correct the dependency statements. Specifically, claims 20 and 21 will read as follows:

20. (Currently amended) Apparatus according to any one of claims 15 to 19, comprising means for causing at least one gas-flow to flow in at least one through-hole (21, 31) of the susceptor system.

21. (Currently amended) Apparatus according to claim 15 characterized in that it is a reactor for the epitaxial growth of silicon carbide or similar material on substrates.

.

A marked up copy of the claims will be further provided for applicant's convenience.